

Guillaume Monier

List of Publications by Year in descending order

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docs citations

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times ranked

1091
citing authors

#	ARTICLE	IF	CITATIONS
1	Investigation of N ₂ plasma GaAs surface passivation efficiency against air exposure: Towards an enhanced diode. Applied Surface Science, 2022, 579, 152191.	6.1	5
2	A new approach to studying the electrical behavior and the inhomogeneities of the Schottky barrier height. European Physical Journal Plus, 2022, 137, .	2.6	1
3	Anomalous ambipolar transport in depleted GaAs nanowires. Physical Review B, 2022, 105, .	3.2	1
4	Charge and spin transport over record distances in GaAs metallic $\langle \text{mml:math} \text{xmlns:mml="http://www.w3.org/1998/Math/MathML"} \rangle \langle \text{mml:mi} \text{xmlns:mml="http://www.w3.org/1998/Math/MathML"} \rangle \langle \text{mml:math} \text{xmlns:mml="http://www.w3.org/1998/Math/MathML"} \rangle$ -type nanowires. Physical Review B, 2021, 103, .	3.2	3
5	Effect of metallic contacts diffusion on Au/GaAs and Au/GaN/GaAs SBDs electrical quality during their fabrication process. Journal of Alloys and Compounds, 2021, 876, 159596.	5.5	5
6	An investigation of adhesion mechanisms between plasma-treated PMMA support and aluminum thin films deposited by PVD. Applied Surface Science, 2021, 564, 150322.	6.1	9
7	Conduction Mechanisms in Au/0.8 nm GaN/GaAs Schottky Contacts in a Wide Temperature Range. Materials, 2021, 14, 5909.	2.9	2
8	The effect of nitridation on the optical properties of InAs quantum dots grown on GaAs substrate by MBE. Vacuum, 2020, 172, 109097.	3.5	4
9	Tailoring the structural and optical properties of bismuth oxide films deposited by reactive magnetron sputtering for photocatalytic application. Materials Chemistry and Physics, 2020, 243, 122580.	4.0	19
10	A new model of thermionic emission mechanism for non-ideal Schottky contacts and a method of extracting electrical parameters. European Physical Journal Plus, 2020, 135, 1.	2.6	6
11	Advances in tailoring the water content in porous carbon aerogels using RT-pulsed fluorination. Journal of Fluorine Chemistry, 2020, 238, 109633.	1.7	6
12	Dynamics of Gold Droplet Formation on SiO ₂ /Si(111) Surface. Journal of Physical Chemistry C, 2020, 124, 11946-11951.	3.1	17
13	Insights into the Structure and the Electrochemical Reactivity of Cobalt-Manganese Layered Double Hydroxides: Application to H ₂ O ₂ Sensing. Journal of Physical Chemistry C, 2020, 124, 15585-15599.	3.1	15
14	Optical and structural analysis of ultra-long GaAs nanowires after nitrogen-plasma passivation. Nano Express, 2020, 1, 020019.	2.4	8
15	Study of GaN layer crystallization on GaAs(100) using electron cyclotron resonance or glow discharge N ₂ plasma sources for the nitriding process. Applied Surface Science, 2019, 495, 143586.	6.1	9
16	Comparative study of ionic bombardment and heat treatment on the electrical behavior of Au/GaN/n-GaAs Schottky diodes. Superlattices and Microstructures, 2019, 135, 106276.	3.1	11
17	Si Doping of Vapor-Liquid-Solid GaAs Nanowires: n-Type or p-Type?. Nano Letters, 2019, 19, 4498-4504.	9.1	26
18	DFT and experimental FTIR investigations of early stages of (O ⁻¹) and (I ⁻¹)B GaAs surface nitridation. Applied Surface Science, 2019, 465, 787-794.	6.1	3

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19	Composition and optical properties tunability of hydrogenated silicon carbonitride thin films deposited by reactive magnetron sputtering. <i>Applied Surface Science</i> , 2018, 444, 293-302.	6.1	18
20	Multi-Mode Elastic Peak Electron Microscopy (MM-EPeM): A new imaging technique with an ultimate in-depth resolution for surface analysis. <i>Ultramicroscopy</i> , 2018, 188, 13-18.	1.9	0
21	Thiol-functionalization of Mn ₅ Ge ₃ thin films. <i>Applied Surface Science</i> , 2018, 451, 191-197.	6.1	4
22	Combined angle-resolved X-ray photoelectron spectroscopy, density functional theory and kinetic study of nitridation of gallium arsenide. <i>Applied Surface Science</i> , 2018, 427, 662-669.	6.1	18
23	Simulation and Experimental Studies of Illumination Effects on the Current Transport of Nitridated GaAs Schottky Diode. <i>Semiconductors</i> , 2018, 52, 1998-2006.	0.5	5
24	Influence of Silicon on the Nucleation Rate of GaAs Nanowires on Silicon Substrates. <i>Journal of Physical Chemistry C</i> , 2018, 122, 19230-19235.	3.1	15
25	Self-catalyzed GaAs nanowires on silicon by hydride vapor phase epitaxy. <i>Nanotechnology</i> , 2017, 28, 125602.	2.6	12
26	MDF treatment with a Dielectric Barrier Discharge (DBD) torch. <i>International Journal of Adhesion and Adhesives</i> , 2017, 79, 18-22.	2.9	11
27	Atomic layer deposition of HfO_2 for integration into three-dimensional metal-insulator-metal devices. <i>Applied Physics A: Materials Science and Processing</i> , 2017, 123, 1.	2.3	5
28	Superhydrophobicity of polymer films via fluorine atoms covalent attachment and surface nano-texturing. <i>Journal of Fluorine Chemistry</i> , 2017, 200, 123-132.	1.7	18
29	Study of the surface state density and potential in MIS diode Schottky using the surface photovoltage method. <i>Molecular Crystals and Liquid Crystals</i> , 2016, 627, 66-73.	0.9	7
30	Synthesis and Study of Stable and Size-Controlled ZnO/SiO ₂ Quantum Dots: Application as a Humidity Sensor. <i>Journal of Physical Chemistry C</i> , 2016, 120, 11652-11662.	3.1	47
31	Spontaneous formation of GaN/AlN core-shell nanowires on sapphire by hydride vapor phase epitaxy. <i>Journal of Crystal Growth</i> , 2016, 454, 1-5.	1.5	5
32	Self-catalyzed growth of GaAs nanowires on silicon by HVPE. , 2016, , .		1
33	Study of the characteristics current-voltage and capacitance-voltage in nitride GaAs Schottky diode. <i>EPJ Applied Physics</i> , 2015, 72, 10102.	0.7	17
34	Effects of the GaN layers and the annealing on the electrical properties in the Schottky diodes based on nitrated GaAs. <i>Superlattices and Microstructures</i> , 2015, 83, 827-833.	3.1	19
35	XPS combined with MM-EPES technique for in situ study of ultra thin film deposition: Application to an Au/SiO ₂ /Si structure. <i>Applied Surface Science</i> , 2015, 357, 1268-1273.	6.1	7
36	Vapor liquid solid-hydride vapor phase epitaxy (VLS-HVPE) growth of ultra-long defect-free GaAs nanowires: Ab initio simulations supporting center nucleation. <i>Journal of Chemical Physics</i> , 2014, 140, 194706.	3.0	11

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37	Energy dependence of the energy loss function parametrization of indium in the Drude-Lindhard model. <i>Surface and Interface Analysis</i> , 2014, 46, 283-288.	1.8	4
38	New method for the determination of the correction function of a hemispherical electron analyser based on elastic electron images. <i>Journal of Electron Spectroscopy and Related Phenomena</i> , 2014, 197, 80-87.	1.7	13
39	Ultralong and Defect-Free GaN Nanowires Grown by the HVPE Process. <i>Nano Letters</i> , 2014, 14, 559-562.	9.1	58
40	Record Pure Zincblende Phase in GaAs Nanowires down to 5 nm in Radius. <i>Nano Letters</i> , 2014, 14, 3938-3944.	9.1	82
41	Real Time Infra-Red Absorption Analysis of Nitridation of GaAs(001) by Hydrazine Solutions. <i>Journal of the Electrochemical Society</i> , 2013, 160, H229-H236.	2.9	3
42	Development of Monte-Carlo simulations for nano-patterning surfaces associated with MM-EPES analysis. <i>Surface Science</i> , 2013, 618, 72-77.	1.9	3
43	Hydride VPE: the unexpected process for the fast growth of GaAs and GaN nanowires with record aspect ratio and polytypism-free crystalline structure. , 2013, , .		0
44	Catalyst-assisted hydride vapor phase epitaxy of GaN nanowires: exceptional length and constant rod-like shape capability. <i>Nanotechnology</i> , 2012, 23, 405601.	2.6	30
45	Passivation of GaAs(001) surface by the growth of high quality c-GaN ultra-thin film using low power glow discharge nitrogen plasma source. <i>Surface Science</i> , 2012, 606, 1093-1099.	1.9	25
46	Carbon diffusion and reactivity in Mn ₅ Ge ₃ thin films. <i>Physica Status Solidi C: Current Topics in Solid State Physics</i> , 2012, 9, 1374-1377.	0.8	5
47	Comparison of InP Schottky diodes based on Au or Pd sensing electrodes for NO ₂ and O ₃ sensing. <i>Solid-State Electronics</i> , 2012, 72, 29-37.	1.4	6
48	Physical and chemical characterizations of nanometric indigo layers as efficient ozone filter for gas sensor devices. <i>Thin Solid Films</i> , 2011, 520, 971-977.	1.8	12
49	Study of the Characteristics Current-Voltage and Capacity-Voltage of Hg/GaN/GaAs Structures. <i>Sensor Letters</i> , 2011, 9, 2268-2271.	0.4	4
50	The dc Electrical Characterization of Hg δ -GaN/n-GaAs Devices, with Different Thicknesses of the GaN Thin Layers. <i>Sensor Letters</i> , 2011, 9, 2211-2214.	0.4	7
51	Monte Carlo simulation for Multi-Mode Elastic Peak Electron Spectroscopy of crystalline materials: Effects of surface structure and excitation. <i>Surface Science</i> , 2010, 604, 217-226.	1.9	6
52	Further insights into the photodegradation of poly(3-hexylthiophene) by means of X-ray photoelectron spectroscopy. <i>Thin Solid Films</i> , 2010, 518, 7113-7118.	1.8	89
53	Fast Growth Synthesis of GaAs Nanowires with Exceptional Length. <i>Nano Letters</i> , 2010, 10, 1836-1841.	9.1	50
54	SEM and XPS studies of nanohole arrays on InP(100) surfaces created by coupling AAO templates and low energy Ar ⁺ ion sputtering. <i>Surface Science</i> , 2009, 603, 2923-2927.	1.9	11

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55	First stages of surface steel nitriding: X-ray photoelectron spectroscopy and electrical measurements. Applied Surface Science, 2009, 255, 9206-9210.	6.1	0
56	On the use of a O ₂ :SF ₆ plasma treatment on GaAs processed surfaces for molecular beam epitaxial regrowth. Applied Surface Science, 2009, 255, 3897-3901.	6.1	5
57	XPS study of the O ₂ /SF ₆ microwave plasma oxidation of (001) GaAs surfaces. Applied Surface Science, 2009, 256, 56-60.	6.1	3
58	Electrical Characterization and Electronic Transport Modelization in the InN/InP Structures. Sensor Letters, 2009, 7, 712-715.	0.4	1
59	XPS, EPMA and microstructural analysis of a defective industrial plasma-nitrided steel. Surface and Coatings Technology, 2008, 202, 5887-5894.	4.8	9
60	Effect of surface roughness on EPES and AREPES measurements: Flat and crenels silicon surfaces. Surface Science, 2008, 602, 2114-2120.	1.9	13
61	XPS study of the formation of ultrathin GaN film on GaAs(100). Applied Surface Science, 2008, 254, 4150-4153.	6.1	14
62	A study of the 42CrMo4 steel surface by quantitative XPS electron spectroscopy. Applied Surface Science, 2008, 254, 4738-4743.	6.1	14
63	Study of porous III-V semiconductors by electron spectroscopies (AES and XPS) and optical spectroscopy (PL): Effect of ionic bombardment and nitridation process. Surface Science, 2007, 601, 4531-4535.	1.9	2
64	Combined EELS, LEED and SR-XPS study of ultra-thin crystalline layers of indium nitride on InP(100) - Effect of annealing at 450°C. Applied Surface Science, 2007, 253, 4445-4449.	6.1	4
65	Interaction of hydrogen with InN thin films elaborated on InP(100). Surface Science, 2007, 601, 3722-3725.	1.9	1